

# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

ATTY DOCKET NO.

WLJ.072

SERIAL NO.

09/763,641 -

Katherine GILES

FILING

FEB. 26, 2001 -

GROUP

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## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	4,894,254	1/16/90	NAKAYAMA et al.			
	4,822,632	4/18/89	WILLIAMS et al.			
	4,096,315	6/20/78	KUBACKI			
	5,786,039	7/28/98	BROUQUET			
	5,641,559	6/24/97	NAMIKI			
	5,593,741	1/14/97	IKEDA			
	5,494,712	2/27/96	HU et al.			
	5,314,724	5/24/94	TSUKUNE et al.			
	5,273,851	12/28/93	TAKEI et al.			
	5,876,503	3/2/99	ROEDER et al.			
	5,730,804	3/24/98	GOMI et al.			

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
	WO 99/41423	8/19/99	PCT			✓	
	EP 0 826 791 A	3/4/98	EPO			✓	
	EP 0 519 079 A	12/23/92	EPO			✓	
	DE 196 54 737 A1	7/3/97	GERMANY			✓	
	WO 98/08249 A	2/26/98	PCT			✓	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	A. Grill et al., "Low Dielectric Constant Films Prepared by Plasma-Enhanced Chemical Vapor Deposition from Tetramethylsilane" Journal of Applied Physics, US, American Institute of Physics, New York, vol. 85, no. 6, 15 March 1999, pages 3314-3318.
	Patent Abstracts of Japan, vol. 1999, no. 02, 26 February 1999 & JP 10 310866 A, 24 November 1998, abstract.

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AC	5,620,524	4/15/97	FAN et al.			
	5,534,069	7/9/96	KUWABARA et al.			
	5,356,034	10/18/94	SCHLUMBERGER			
	5,195,655	3/23/93	BUKHMAN			
	5,098,741	3/24/92	NOLET et al.			
	5,095,938	3/17/92	GARRISON			
	4,793,524	12/27/88	STARR			
AG	3,223,040	12/14/65	DINKELKAMP			

## FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO
AC	WO 99/43866	9/2/99	PCT			✓	
	GB 2111064 A	6/29/83	UK			✓	
	GB 2108133 A	5/11/83	UK			✓	
	0 826 791 A2	3/4/98	EPO			✓	
AG	0 726 599 A2	8/14/96	EPO			✓	

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


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		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
AG		0 254 205 A2	7/19/86	EPO				✓
		0 212 691 A1	3/4/97	EPO			✓	
		WO 94/01885	1/20/94	PCT			✓	
		GB 2280169 A	1/25/95	UK			✓	
AG		GB 2220869 A	1/24/90	UK			✓	


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